Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	_	04 Dec
Lecture 2	—	07 Dec
Lecture 3	-	11 Dec
Lecture 4	—	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/

Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	—	04 Dec
Lecture 2	-	07 Dec
Lecture 3	-	11 Dec
Lecture 4	-	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/ Note about the delivery of these lectures:

- Incomplete slides distributed at the beginning of each lecture
- Mix of slideshow and writing down on the blackboard
- Complete slides posted online at the end of the 5 lectures
- Although the timing is very tight, asking/sending questions is encouraged
- 'Quiz Test' on the lectures: December 21

vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/



1h30

1130

III. Spin accumulation – CPP-GMR

 $1h^{30}$ IV. Transfer of angular momentum – STT

V. Berry curvature, parity and time symmetries – AHE

VI. Brief non-exhaustive introduction to current topics



1. Spin in electronics



1. Spin in electronics

Electronics exploits charge transport Unpolarized currents

Spin electronics exploits spin transport

- on top of moving charges: electronic transport
 - Polarized currents in magnetic materials
 - Pure spin current in magnetic & non-magnetic materials
- via exchange interactions: magnonic transport/spin waves
 - Pure spin current in magnetic materials

This series of lectures:

- focuses on the electronic transport of spin
- introduces some key underlying physical principles of spintronics

First, brief introduction to:

- some of the flagship applications of spintronics





Nature 464, 262 (2010)

2. The example of two success stories



2. The example of two success stories



3. Many more to come

Many more success stories to come



Numerous fields of applications:

- Information technology IT (e.g. memory, processors, data security)
- Biomedical (e.g. sensors)
- Telecommunication (e.g. transceiver)
- Artificial intelligence AI (e.g. neuromorphic computing)

3. Many more to come

Many more success stories to come

'More transistors and magnets are produced in fabs than grains of rice are grown in paddy fields' (tcd Dublin)



The goal of this series of lectures is: to give you the basic knowledge to understand most of the underlying physical principles of spintronics

Different transport regimes



 $\psi(\mathbf{r}, t)$: wavefunction $f(\mathbf{r}, \mathbf{k}, t)$: distribution function $n(\mathbf{r}, t)$: density

Notation: **bold** is used for vectors, e.g. $r = \vec{r}$

II. First notions to describe electron and spin transport – AMR, CIP-GMR 2. The two current model

Majority moment (\uparrow)-spin(\Downarrow) and minority moment (\downarrow)-spin(\Uparrow) electrons are considered to flow in separate channels. This is known as the two current model. It was introduced in 1936 by N. F. Mott.



II. First notions to describe electron and spin transport – AMR, CIP-GMR 3. Drude model, mean free path



Master 2 N2 UGA - lecture Baltz, V

II. First notions to describe electron and spin transport – AMR, CIP-GMR 3. Drude model, mean free path



DOI: 10.1051/978-2-7598-2917-0.c002

In the next slides, we will explain why τ_e is spin-dependent, making $\mathbf{j}^{\uparrow} \neq \mathbf{j}^{\downarrow}$

Spin-dependent generalized Ohm's law $i \uparrow (l) \land \uparrow (l) \lor \uparrow (l)$

(2 equations)

II. First notions to describe electron and spin transport – AMR, CIP-GMR 4. Band structures and spin-dependent Fermi surface

In metals, conduction processes occur at or near the Fermi surface (for $\varepsilon = \varepsilon_F$)



II. First notions to describe electron and spin transport – AMR, CIP-GMR 4. Band structures and spin-dependent Fermi surface

Ferromagnets have different Fermi surfaces for majority moment (\uparrow) -spin (\Downarrow) and minority moment (\downarrow) -spin (\Uparrow) electrons => spin-dependent conduction processes



II. First notions to describe electron and spin transport – AMR, CIP-GMR 5. Localized vs itinerant ferromagnetism

Partial density of state (DOS) of *3d* transition metals for majority moment (\uparrow) -spin (\Downarrow) and minority moment (\downarrow) -spin (\Uparrow) electrons

DOS = number of continuum states in an infinitesimally small energy interval ε + d ε



Master 2 N2 UGA - lecture Baltz, V

Physics of Low Dimensional Systems, Springer, Boston

In transition metals, spins contributing to transport are split in two types:

- localized spins carried by heavy 3*d*-electrons
- itinerant spins carried by light 4s-electrons



 N^{\uparrow}

s¹

Elastic scattering between itinerant *s*-electrons and localized *d*-electrons is considered. This is known as the *s*-*d* model.

Because m^{*}(*d*) >> m^{*}(*s*), *J* is mostly carried by *s*-electrons

Scattering of electrons is determined by $N^{\uparrow(\downarrow)}(\varepsilon_F)$

Fermi's golden rule:



6. The two current and s-d models



DOI: 10.1051/978-2-7598-2917-0.c002

$$\tau_e$$
 is spin-dependent, making $\mathbf{j}^{\uparrow} \neq \mathbf{j}^{\downarrow}$

Spin-dependent generalized Ohm's law

$$\boldsymbol{j}^{\uparrow(\downarrow)} = \sigma^{\uparrow(\downarrow)} \frac{\boldsymbol{\nabla} \boldsymbol{\mu}^{\uparrow(\downarrow)}}{e}$$

Master 2 N2 UGA - lecture Baltz, V

6. The two current and s-d models



7. From impurity scattering to heterostructures

<u>Impurity control over a layer's resistance – the case of a ternary alloy</u>



7. From impurity scattering to heterostructures

Relative direction of magnetization control over a stack's resistance – CIP-GMR

The initial idea underlying the giant magnetoresistance effect (GMR) is to replace the two types of impurities by two ferromagnetic layers (Fs)

Antiparallel (AP) state = type 1: Electrons flow is altered in the two spin-channels

Parallel (P) state = type 2: Electrons flow is altered in one spin-channel only



7. From impurity scattering to heterostructures



Notes:

- The relative orientation of the layers'magnetization can for example be controlled by field and spin-torques (see lecture 3).
- An important effect sharing similarities with CIP-GMR is known as the interlayer exchange coupling (IEC) (next set of slides), closely related to Ruderman–Kittel–Kasuya–Yosida (RKKY) interactions between magnetic impurities.

- GMR: the thickess of the non-magnetic (N) spacer-layer, $\underline{d}_{\underline{N}}$ is fixed - the relative alignement of the magnetic layers (M₁, M₂) is varied by the user
 - (eg with an external magnetic field, a current), leading to a change in resistance



Electrons flow is altered in the two spin-channels

Parallel (P) state

Low resistance



Electrons flow is altered in ~one spin-channel only (the spin down channel)

IEC: - the thickess of the non-magnetic (N) spacer-layer, $\underline{d_N}$ is varied, directly leading to a change in resistance





1D electron quantum well behavior for the minority moment(\downarrow)-spin(\Uparrow) electrons with d_N -dependent quantized energy levels (ε_n)

IEC: - the thickess of the non-magnetic (N) spacer-layer, $\underline{d_N}$ is varied, directly leading to a change in resistance





1D electron quantum well behavior for the minority moment(\downarrow)-spin(\Uparrow) electrons with d_N -dependent quantized energy levels (ε_n)

'For increasing d_N , the levels move downward. When a level crosses the Fermi energy E_F , the QWS is populated, and the total energy increases. When the QWS level moves further below E_F , the energy again decreases until the next level approaches E_F .'

IEC: - the thickess of the non-magnetic (N) spacer-layer, $\underline{d_N}$ is varied, directly leading to a change in resistance





1D electron quantum well behavior for the minority moment(\downarrow)-spin(\Uparrow) electrons with d_N -dependent quantized energy levels (ε_n)

Thus, for the P alignment, the energy oscillates with d_N .

In contrast, for the AP alignment (no QWS) the energy stays still. To always take the configuration with the lowest energy, the alignment switches between P and AP when d_N increases, and hence the coupling oscillates between + and – and the GMR oscillates between high and low R.



Some numbers



CIP-GMR, 1st experiments (1988-1989)

A. Fert and P. Grünberg Nobel Prize 2007





Spin-valve, 1st experiment (1991) see lecture 2 for CPP-GMR, typical best values for GMR: few 10th of % at 300K (see M1 for TMR of few 100th of %)

Several billions of sensors,

e.g. in hard disk drives

Note:

- Remember that the important characteristic length in CIP-GMR is the (spin-dependent) electron mean free path $(\lambda_e^{\uparrow(\downarrow)})$, as opposed to current perpendicular-to-plane (CPP)-GMR, where spin diffusion length (l_{sf}^*) is the one to consider (see lecture 2), with $l_{sf}^* > \lambda_e$.

The example of MR in read-heads of hard-disk drives for data storage



Master 2 N2 UGA - lecture Baltz, V

10. Spin mixing and spin-orbit interactions


No mixing between the two spin-channels



Mixing between the two spin-channels, $\rho^{\uparrow\downarrow}$, e.g. due to spin-orbit interactions

$$\rho = \frac{\rho^{\uparrow} \rho^{\downarrow} + \rho^{\uparrow\downarrow} (\rho^{\uparrow} + \rho^{\downarrow})}{\rho^{\uparrow} + \rho^{\downarrow} + 4\rho^{\uparrow\downarrow}} \qquad \rho^{\downarrow}/2 \qquad \rho^{\uparrow}/2 \qquad \rho^{\uparrow}/2 \qquad \rho^{\uparrow}/2 \qquad \rho^{\uparrow}/2 \qquad \rho^{\downarrow}/2 \qquad \rho^{$$

Spin-orbit interaction couples the spin, *S*, and the orbital, *L*, angular momentum of an electron. In 3*d* transition metals, this results in:

- a lift of the degeneracy of the energy states of majority- and minority-spins

 $H = \xi_{so} L.S$

- a 'mix/reorientation' of the *d* orbitals (l = 2; $m_l = -2, -1, 0, +1, +2$)

 $\int_{d_{x^2-y^2}} v \int_{d_{z^2}} v \int_{d_{z^2}$

with $L S = L_x S_x + L_y S_y + L_z S_z = L_z S_z + \frac{1}{2} (L^+ S^- + L^- S^+)$

The ladder operators depend on the quantum numbers as follows:

 $L^{+(-)}|l,m_l\rangle = \sqrt{l(l+1) - m(m+(-)1)}\hbar|l,m_l+(-)1$ $S^{+(-)}|s,m_s\rangle = \hbar|s,m_s+(-)1\rangle$

$$3d^{\uparrow(\downarrow)}(m_l) \rightarrow 3d^{\downarrow(\uparrow)}(m_l + (-)1)$$

Numbers: $\xi_{SO} \sim 1 \text{ meV}$ in Ni

Master 2 N2 UGA - lecture Baltz, V

II. First notions to describe electron and spin transport – AMR, CIP-GMR

10. Spin mixing and spin-orbit interactions

Partial density of state (DOS) of *3d* transition metals for majority moment (\uparrow) -spin (\Downarrow) and minority moment (\downarrow) -spin (\Uparrow) electrons



Simplistic illustration of mixing of *d*-bands due to spin-orbit interactions. The majority moment (\uparrow)-spin(\Downarrow) *d*-band acquires a minority moment (\downarrow)-spin(\Uparrow) character and vice versa.

II. First notions to describe electron and spin transport – AMR, CIP-GMR

10. Spin mixing and spin-orbit interactions



II. First notions to describe electron and spin transport – AMR, CIP-GMR 11. The example of anisotropic magnetoresistance (AMR)

Spin-orbit interactions will depend on the direction of the angular momentum of *s*-electrons (parallel to the wavevector $\hbar k$) relative to that of the *d*-electrons (parallel to *M*).

Phenomenological picture:

- $I \parallel M$: the electronic orbits are \perp to I, offering a large cross section for the *s*-electrons to scatter (high resistivity, ρ_{\parallel})
- when $I \perp M$: the electronic orbits are \parallel to I and thus offer a smaller cross section for scattering (low resistivity, ρ_{\perp}).



This is known as the anisotropic magnetoresistance (AMR) effect. It was demonstrated experimentally by W. Thomson (Lord Kelvin) in 1857 and explained theoretically e.g. by the Campbell, Fert and Jaoul model (CFJ) in 1970.

II. First notions to describe electron and spin transport – AMR, CIP-GMR

11. The example of anisotropic magnetoresistance (AMR)

Some numbers



Angular dependence of AMR, cf. Exercice 1



- Models and their degree of 'Quantumness'
 - Phenomenological vs. classical vs ½ classical vs quantum
- Electronic transport
 - Drude, Band structures, DOS and Fermi level
- Electronic spin-dependent transport
 - The two current / s-d models and spin-dependent relaxation (electron mean free path)
 - Spin-orbit interactions and spin mixing, the example of the AMR effect
 - Spin-dependent scattering in heterostructures, the example of the CIP-GMR effect

- References:

- A. Fert, Reflets Phys. 15, 5 (2009) and references therein
- P. S. Bechthtold **B7**, in S. Blügel *et al* (eds) Spintronics from GMR to quantum information (2009)
- P. Grünberg et al, Metallic Multilayers, in Y. Xu Y. et al (eds) Handbook of Spintronics, Springer (2015)
- AMR, CFJ model: I. A. Campbell et al, J. Phys. C: Solid State Phys. 3, S95 (1970)
- AMR, a review: T. R. McGuire et al, IEEE Trans. Magn. 11, 1018 (1975)
- CIP-GMR: M. N. Baibich et al, Phys. Rev. Lett. 61, 2472 (1988), G. Binasch et al, Phys. Rev. B 39, 4828 (1989)
- Spin-valve: B. Dieny, J. Magn. Magn. Mater. 136, 335 (1994)
- MR in HDDs: E. Dobisz *et al*, Proc. IEEE **96**, 1836 (2008)

Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	—	04 Dec
Lecture 2	_	07 Dec
Lecture 3	_	11 Dec
Lecture 4	-	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/

- I. Brief overview of the field of spintronics and its applications
- II. First notions to describe electron and spin transport AMR, CIP-GMR



1h30

- III. Spin accumulation CPP-GMR
- 1h30

1h30

- IV. Transfer of angular momentum STT
- V. Berry curvature, parity and time symmetries AHE
- VI. Brief non-exhaustive introduction to current topics



Exercise 1 - Anisotropic magnetoresistance (AMR) Exercise 2 – The spin pumping (SP) and inverse spin Hall effects (ISHE)

0. Characteristic lengths, Extended Drude model, notion of electrochemical potential

Electron mean free path

$$\lambda_e = v_F \tau_e$$



0. Characteristic lengths, Extended Drude model, notion of electrochemical potential



1. Spin accumulation at a single interface

Distinct densities of current at the interface between materials of different types (e.g. F and NM) creates a spin imbalance.

This effect is called spin accumulation.

Relaxation towards equilibrium conditions causes spins to diffuse near the interface. The *average* spin-diffusion length $(l_{sf,F(N)}^*)$ is the characteritic length for this effect.



1. Spin accumulation at a single interface

Drude model of electronic transport

$$j = \sigma E \qquad \text{with} \quad \sigma = \frac{N(\varepsilon_{\rm F})e^2\tau_e}{m_e} = N(\varepsilon_{\rm F})e^2D$$
$$j = \sigma \frac{\nabla \mu_e}{e} \qquad \text{with} \quad E = -\nabla V \quad \text{electric potential}$$
$$\text{and} \quad \mu_e = -eV \quad \text{electrostatic potential}$$

Drift-diffusion and generalized Ohm's law = $\nabla \mu$ where $p = \mu + \mu$ is the electro demind potential and $\mu_n = \mu_{no} + \frac{e^2 p}{5} \delta_n$ is the chemical potential at equilission = $\frac{\delta_n}{M(E_F)}$

1. Spin accumulation at a single interface



In the next slides, we will explain how to determine: - the spin imbalance: $\mu_s = -(\mu^{\uparrow} - \mu^{\downarrow})$ - the spin current: $J_s = -(j^{\uparrow} - j^{\downarrow})$

1. Spin accumulation at a single interface



1. Spin accumulation at a single interface



 $\nabla_{\mu_{s}}^{2} - \frac{\mu_{s}}{p_{s}}^{2} = 0$ where l_{s}^{*} can be viewed as an arraye $s_{\mu_{s}}^{2} - \frac{\mu_{s}}{p_{s}}^{2} = 0$ spin-Jiffwin length: $\frac{1}{p_{s}}^{2} = \frac{1}{p_{s}}^{2} + \frac{1}{p_{s}}^{2}$

Master 2 N2 UGA - lecture Baltz, V

1. Spin accumulation at a single interface



(6) In a 1D problem, the solutions of Eq. (5) take the following form:

$$V_{S, F(N)}(x) = A_{F(N)}e^{\gamma(SF, F(N))} + B_{F(N)}e^{\gamma(SF, F(N))} +$$

(/) boundary conditions for infinite layers.

$$P_{S,F}(0) = P_{S,N}(0)$$
 and $J_{S,F}(0) = J_{S,N}(0)$

(9) Using Eqs. (6) to (8), it is possible to calculate the spin accumulation and the charge current in the F/N bilayer.

Example and detailed calculations, cf. Exercice 2

1. Spin accumulation at a single interface



Master 2 N2 UGA - lecture Baltz, V

1. Spin accumulation at a single interface



Spin-coupled interface resistance:

Rs = - $\overline{J}e = \frac{SPe}{e\overline{J}e} = \frac{Ps, F(0)}{e\overline{J}e} = \frac{Ps, N(0)}{e\overline{J}e}$ spin uccumulation over finite langt is relagate a discontinuity of electrostatic plential : Ope

1. Spin accumulation at a single interface



Master 2 N2 UGA - lecture Baltz, V

2. Spin accumulation in heterostructures – the example of CPP-GMR



2. Spin accumulation in heterostructures – the example of CPP-GMR



Equivalent circuits (for
$$d_{N(F)} \ll l_{sf,N(F)}^{*}$$
)

CPP-GMR = $\frac{\rho^{AP} - \rho^{P}}{\rho^{AP}} = \beta^{2} \frac{(2\rho_{F}^{*}d_{F})^{2}}{(\rho_{N}^{*}d_{N} + 2\rho_{F}^{*}d_{F})^{2}}$

3. Interfacial spin-dependent scattering

- In the previous slides on CPP-GMR, only bulk spin-dependent scattering was considered.
- Refined models must consider interfaces, because e. g. decoherent roughness-induced stray fields and changes in the local DOS creates:
- 1) interfacial spin-dependent electronic scattering ($\tau_{e,interface}^{\uparrow} \neq \tau_{e,interface}^{\downarrow}$).



Bulk
$$\rho_F^{\uparrow(\downarrow)} = 2\rho_F^*(1 \mp \beta)$$

with $\beta = \frac{\alpha - 1}{1 + \alpha}$ and $\alpha = \frac{\rho_F^{\downarrow}}{\rho_F^{\uparrow}}$

Interface
$$r_{interface}^{\uparrow(\downarrow)} = 2r_b^*(1 \mp \gamma)$$

The interface is considered as an infinitesimally thin extra layer, and the electrochemical potential is no more continuous, giving rise to extra resistances in series in each spin-channel. An interfacial spin asymmetry parameter (γ) is introduced.

Master 2 N2 UGA - lecture Baltz, V

3. Interfacial spin-dependent scattering

2) interfacial spin-dependent spin-flip scattering $(\tau_{interface}^{\uparrow\downarrow(\downarrow\uparrow)})$ to account for the fact that only a fraction of the spin current coming from the F layer effectively reaches the N layer. This effect is called the spin memory loss (SML). It is modelled by the following ratio:

$$F = N \Rightarrow F = N R_{SML} = \frac{J_s(x = d_{interface})}{J_s(x = 0)}$$

$$R_{SML} = \frac{J_s(x = d_{interface})}{J_s(x = 0)}$$

The interface is considered as thin extra layer with finite dimensions, $t_{interface}$ and possessing a finite spin-flip length, $l_{sf,interface}^*$. Spin-flipping by the interface is modelled by the interfacial spin-flip parameter, $\delta = d_{interface}/l_{sf,interace}^*$



4. Numbers

$$\begin{cases} J_{s,F}(x) = \beta J_{e} \left[1 - \left(1 + \frac{l_{sf,F}^{*} \rho_{F}^{*}}{l_{sf,N}^{*} \rho_{N}} \right)^{-1} e^{\frac{x}{l_{sf,F}^{*}}} \right] &+ f(r_{b}^{*}, \gamma) \\ J_{s,N}(x) = \beta J_{e} \left(1 + \frac{l_{sf,N}^{*} \rho_{N}}{l_{sf,F}^{*} \rho_{F}^{*}} \right)^{-1} e^{-\frac{x}{l_{sf,N}^{*}}} &+ f(\rho_{inter} l_{sf,inter}^{*}, \delta) \end{cases}$$

Interface

Bulk

Material	Measured resistivity 4K/ 300K	β Bulk scattering asymmetry	l [*] _{sf}
Cu	0.5-0.7μΩ.cm 3-5	0	500nm 50-200nm
Au	2μΩ.cm 8	0	35nm 25nm
Ni ₈₀ Fe ₂₀	10-15	0.73-0.76	5.5
	22-25	0.70	4.5
Ni ₆₆ Fe ₁₃ Co ₂₁	9-13	0.82	5.5
	20-23	0.75	4.5
Co	4.1-6.45	0.27 – 0.38	60
	12-16	0.22-0.35	25
Co ₉₀ Fe ₁₀	6-9	0.6	55
	13-18	0.55	20
Co ₅₀ Fe ₅₀	7-10	0.6	50
	15-20	0.62	15
Pt ₅₀ Mn ₅₀	160 180	0	1 1
Ru	9.5-11	0	14
	14-20	0	12

Material	Measured R.A interfacial resistance	γ Interfacial scattering assymetry
Co/Cu	0.21mΩ.μm² 0.21-0.6	0.77 0.7
Co ₉₀ Fe ₁₀ /Cu	0.25-0.7 0.25-0.7	0.77 0.7
Co ₅₀ Fe ₅₀ /Cu	0.45-1 0.45-1	0.77 0.7
NiFe/Cu	0.255 0.25	0.7 0.63
NiFe/Co	0.04 0.04	0.7 0.7
Co/Ru	0.48 0.4	-0.2 -0.2
Co/Ag	0.16 0.16	0.85 0.80

Material	$ ho_I l_{sf}^*$, inter Interfacial spin resistance	δ Interfacial spin-flip parameter
Co/Cu	2 fΩ.m²	0.25
Cu/Pt	1.7	0.9
Co/Pt	0.83	0.9
Co/Cu/Pt	0.85	1.2

Phys. Rev. B 73, 184418 (2006) Handbook of Spintronics, Springer, Dordrecht (2016)

 $\mu_s \sim 10 - 100 \ \mu eV$ $J_e \sim 10^5 - 10^6 \ A. \ cm^{-2}$



5. 3-dimensionality, non-uniformity, non-collinearity

- In the uniform 1D GMR formalism, it is convenient to describe spin accumulation with electrochemical potentials, μ_s , to match theory with electrical measurements.

- A spin accumulation can also be described by a net magnetization m. Using this latter formalism is for example convenient when considering interactions between spin accumulation and the layer's magnetization M, e.g. for spin transfer torque (see lecture 3).



 $m \sim 0.0001 \mu_B$ per atom versus $m_{ferro} \sim 1 \mu_B$ per atom

5. 3-dimensionality, non-uniformity, non-collinearity

The use of m also implicitly recalls that spin accumulation is described by a vector. This is especially needed to deal with 3D, non-uniformity (e.g. of J_e) and non-collinearity (e.g. between M of several layers).

Finally, note that because spin accumulation is described by a vector in the general case (3 components of m), spin current is described by a 3x3 tensor (3 components of J_s flowing along 3 directions in space).



The color map indicates the amplitude of the charge current, J_e (scalar). The arrows indicate the flow of charges, J_e (vector).

The color map indicates the amplitude of the ycomponent of spin accumulation, m_y (scalar). The arrows indicate the corresponding flow of y-spins, J_s^y (vector).

5. 3-dimensionality, non-uniformity, non-collinearity



The color map indicates the amplitude of the ycomponent of spin accumulation, m_y (scalar). The arrows indicate the corresponding flow of y-spins



$$J_{s} = \overline{J}_{s} = \begin{bmatrix} J_{s}^{(x)} & J_{s}^{(y)} & J_{s}^{(z)} \end{bmatrix}$$

$$\overline{J}_{s} = \begin{bmatrix} J_{s}^{(x)} & \gamma & z \\ s & \gamma &$$

5. 3-dimensionality, non-uniformity, non-collinearity

Spin accumulation (*m*) also exists in magnetic textures like domain walls (DWs), when the spins of the itinerant *s*-electrons are unable to follow magnetization (*M*) (spin-mistracking). However, spin accumulation in DW most often gives rise to negligible resistance in the diffusive regime. This DW effect coexists with other contributions: one is called 'intrinsic' domain wall magnetoresistance (DWMR) and arises from spin-dependent scattering subsequent to spin-mistracking; another relates to AMR (DWAMR) due to SO-interactions.



See also lecture 3 for spin transfer torque in DWs.

- Electronic transport

- Electron mean free path vs. Spin diffusion length
- Electrochemical potential
- Spin accumulation at a single interface (the Valet/Fert ½classical model)
 - Drift-diffusion equations to describe spin currents + Boundary conditions
 - Impedance matching
 - Interface (spin-dependent scattering, spin-flip scattering)
- Spin accumulation in heterostructures
 - The example of the CPP-GMR effect
- References:
 - A. Fert, Reflets Phys. **15**, 5 (2009) and references therein
 - P. S. Bechthtold **B7**, in S. Blügel *et al* (eds) Spintronics from GMR to quantum information (2009)
 - G. Zahnd, PhD thesis manuscript (2017), https://tel.archives-ouvertes.fr/tel-01791039v2/document
 - Theory of CPP-GMR: T. Valet and A. Fert, Phys. Rev. B 48, 7099 (1993)
 - 1st exp: W. P. Pratt *et al*, Phys. Rev. Lett. **66**, 3060 (1991)
 - Numbers: J. Bass and W. P. Pratt, J. Phys. Cond. Mat. **19**,183201 (2007);
 - N. Strelkov et al, J. App. Phys. 94, 3278 (2003)
 - Non-uniformity: N. Strelkov et al, Phys. Rev. B 84, 024416 (2011)
 - Impedance mismatch: A. Fert and H. Jaffrès, Phys. Rev. B 64, 184420 (2001)
 - Spin memory loss: J.-C. Rojas-Sánchez et al, Phys. Rev. Lett. 112, 106602 (2014).

Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	—	04 Dec
Lecture 2	—	07 Dec
Lecture 3	_	11 Dec
Lecture 4	-	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/

- I. Brief overview of the field of spintronics and its applications
- II. First notions to describe electron and spin transport AMR, CIP-GMR



1h30

III. Spin accumulation – CPP-GMR

IV. Transfer of angular momentum – STT

- V. Berry curvature, parity and time symmetries AHE
- VI. Brief non-exhaustive introduction to current topics



1h3C

Exercise 1 - Anisotropic magnetoresistance (AMR)

Exercise 2 – The spin pumping (SP) and inverse spin Hall effects (ISHE)

IV. Transfer of angular momentum – STT

Spin transfer torque (STT) and giant magnetoresistance (GMR) are reciprocal effects.



Fig. 1: Phenomenology of (a) GMR and (b) current-induced magnetization switching. (a) The electric resistance of a trilayer structure consisting of two ferromagnets separated by a non-magnetic, metallic interlayer depends on the alignment of the layer magnetizations. (b) The stable alignment of the magnetizations depends on the polarity, i.e. the direction, of the current flowing perpendicularly through the trilayer.
0. Reminder





Spin accumulation m and magnetization M_{free} are coupled via the *sd* exchange interactions:

In the reference frame of the s-electrons, m experiences an effective field and a subsequent torque created by M_{free} :

Ha Jod Moree

Conversely, in the reference frame of the layer's magnetization, M_{free} also experiences an effective field and a torque (called the spin tranfer torque, STT) due to m:

Conservation of total angular momentum gives (if all other relaxation channels are closed): $\frac{dm}{dt} = -\frac{dM_{free}}{dt}$

1. Spin accumulation and *sd* coupling

Only projections of m perpendicular to M_{free} give rise to an actual torque. Therefore, STT is often written and discussed as follows:



Notes: $-\tau_{DL}$ and τ_{FL} depend on material (e.g. M_s), geometry, current (J)

m depends on the effect that gave rise to spin accumulation.
 Directions of FL and DL torques may be inverted depending on the direction of *m*.
 For STT, *m* || *M*_{pinned}. In some other structures for spintronics, effects arising from spin-orbit coupling, like spin-Hall and Rashba, can give rise to different spin accumulation and torques. These torques are called spin-orbit torques, SOT (see lecture V).

1. Spin accumulation and *sd* coupling



In the next slides, we will discuss toy models to:

- determine T
- see how magnetization is influenced by T

Reminder about the quantum mechanical treatment of charge and spin:

Charge

Spin

density of charge

 $\rho = -e\langle \psi | \psi \rangle$

density of charge current $J_e = -e\mathcal{R}e(\langle \psi | \mathbf{v} | \psi \rangle)$ $= \frac{e\hbar}{m} \Im m(\langle \psi | \boldsymbol{\nabla} | \psi \rangle)$

density of spin

 $S = \langle \psi | S | \psi \rangle = \frac{\pi}{2} \langle \psi | \sigma | \psi \rangle$ density of spin current

density of spin current $Q = J_s = \mathcal{R}e(\langle \psi | \mathbf{S} \otimes \mathbf{v} | \psi \rangle)$ $= -\frac{\hbar^2}{2m} \Im m(\langle \psi | \boldsymbol{\sigma} \otimes \boldsymbol{\nabla} | \psi \rangle)$

 ψ is the spinor, here spin-half electron wave function \mathbf{v} is the velocity operator \mathbf{S} is the spin operator, linked to the Pauli operator, $\boldsymbol{\sigma}$ with $\sigma^x = \begin{pmatrix} 0 & 1 \\ 1 & 0 \end{pmatrix}$, $\sigma^y = \begin{pmatrix} 0 & -i \\ i & 0 \end{pmatrix}$, and $\sigma^z = \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$; z= quantification axis

2. Quantum mechanical model



Conservation of total angular momentum 'Nothing is lost, nothing is created, everything is transformed'

Ds + USm = 0 => USm = USm = Sin 6

Note: the propagation terms (e^{ikx} and e^{-ikx} in $\psi_{i(t)}$ and ψ_r) were ommited here to facilitate the message delivery. 78

Master 2 N2 UGA - lecture Baltz, V

2. Quantum mechanical model

Calculation of the spin components (Homework)

$$\mathbf{s} = \langle \psi | \mathbf{S} | \psi \rangle$$
 with $\mathbf{S} = \frac{\hbar}{2} \sigma$
Initial state
 $s_i^x = \langle \psi_i | \mathbf{S}^x | \psi_i \rangle = \begin{pmatrix} cos \frac{\theta}{2} & sin \frac{\theta}{2} \\ 2 & vin \frac{\theta}{2} \end{pmatrix} \frac{f_i}{2} \begin{pmatrix} cos \frac{\theta}{2} \\ 0 & n \end{pmatrix} \begin{pmatrix} cos \frac{\theta}{2} \\ sin \frac{\theta}{2} \end{pmatrix} = \frac{f_i}{2} 2 \cos \frac{\theta}{2} \sin \frac{\theta}{2}$
Final state
Final state

Fillal State

$$s_t^{x} = \langle \psi_t | \mathbf{S}^{x} | \psi_t \rangle =$$
$$s_t^{z} = \langle \psi_t | \mathbf{S}^{z} | \psi_t \rangle =$$

$$s_r^x = \langle \psi_r | \mathbf{S}^x | \psi_r \rangle =$$

 $s_r^z = \langle \psi_r | \mathbf{S}^z | \psi_r \rangle =$

Loss

$$\Delta s^{x} = (s_{t}^{x} + s_{r}^{x}) - s_{i}^{x} =$$
 and $\Delta s^{z} = (s_{t}^{z} + s_{r}^{z}) - s_{i}^{x} =$

Master 2 N2 UGA - lecture Baltz, V

2. Quantum mechanical model



$$\Delta S_M = \Delta S_M^{\mathcal{X}} \widehat{\mathbf{x}} = \frac{\hbar}{2} \sin \theta \, \widehat{\mathbf{x}} = \mathbf{s}_{\perp}$$

It is said that the transverse component of spin angular momentum is absorbed.

This absorption was actually the result of a torque, T, acting on S_M .

2. Quantum mechanical model



The spin transfer torque, *T*, can directly be calculated from the flux of spin current entering and leaving the effective volume impacted:

$$T = -\iint \widehat{x} \cdot Q dA = A \widehat{x} \cdot (Q_i + Q_r - Q_t)$$
$$T = \frac{A}{V_{eff}} \frac{\hbar^2 k}{2m} \sin \theta \, \widehat{x} = \frac{A}{V_{eff}} \frac{\hbar^2 k}{2m} \widehat{S_M} \times (\widehat{s} \times \widehat{S_M})$$

Here, we see that **T** is damping-like.

2. Quantum mechanical model

Calculation of the torque (Homework)
pensity of spin current:

$$Q = -\frac{\hbar}{m}\Im m(\langle \psi | \mathbf{S} \cdot \nabla | \psi \rangle) \quad \text{with } Q^{ab} = -\frac{\hbar}{m}\Im m(\langle \psi | \mathbf{S}^a \cdot \nabla_b | \psi \rangle)$$

$$= -\frac{\hbar k_b}{m}\langle \psi | \mathbf{S}^a | \psi \rangle$$

$$= -\frac{\hbar k_b}{m} s^a$$

$$Q = \overline{Q} = -\frac{\hbar k_x}{m} \begin{bmatrix} s^x & s^y & s^z \\ 0 & 0 & 0 \\ 0 & 0 & 0 \end{bmatrix} \quad \text{and} \quad \widehat{\mathbf{x}} \cdot \mathbf{Q} = \frac{\hbar k_x}{m} (s^x + s^y + s^z) \widehat{\mathbf{x}}$$

Torque: $T = \hat{x} \cdot (Q_i + Q_r - Q_t)$ $T = -\frac{\hbar k_x}{m} (\Delta s^x + \Delta s^y + \Delta s^z) \hat{x}$ $T = \frac{\hbar^2 k_x}{2m} \sin \theta \, \hat{x}$

For calculations of Δs^x , Δs^y , Δs^z , cf. slide 10.

2. Quantum mechanical model





These ingredients are taken into account by considering complex number transmission $(t_{\downarrow}, t_{\uparrow})$ and reflection $(r_{\downarrow}, r_{\uparrow})$ coefficients. Below is the example with spin dephasing upon reflection:

$$Q_r^{xx} = -\frac{\hbar k_x}{m} \sin\theta \,\mathcal{R}e\big(r_{\uparrow\uparrow}^* r_{\downarrow\downarrow} e^{i\phi}\big)$$

$$Q_r^{yx} = -\frac{n\kappa_x}{m}\sin\theta\,\Im m\big(r_{\Uparrow}^*r_{\Downarrow}e^{i\phi}\big)$$

with, by definition,
$$r_{\uparrow\uparrow}^* r_{\downarrow\downarrow} = |r_{\uparrow\uparrow}^* r_{\downarrow\downarrow}| e^{i\delta\phi}$$



Describes reflection along axes transverse to $S_M \parallel \hat{z}$. This term relates to the transverse reflection coefficient or the spin-mixing coefficient (mixing stands for mixing of the eigen states no spin-flip is involved).

(Advanced) It is the spin-mixing conductance in the magnetoelectronic circuit theory.



When dephasing is introduced by considering complex transmission $(t_{\uparrow}, t_{\downarrow})$ and reflection $(r_{\uparrow}, r_{\downarrow})$ coefficients, both DL and FL terms contribute to the torque:

$$T = \frac{A}{V_{eff}} \frac{\hbar^2 k}{2m} \sin \theta \left[\left(1 - \mathcal{R}e(t_{\uparrow\uparrow} t_{\downarrow\downarrow}^* + r_{\uparrow\uparrow} r_{\downarrow\downarrow}^*) \right) \widehat{x} - \Im m(t_{\uparrow\uparrow} t_{\downarrow\downarrow}^* + r_{\uparrow\uparrow} r_{\downarrow\downarrow}^*) \widehat{y} \right]$$
$$T = \frac{A}{V_{eff}} \frac{\hbar^2 k}{2m} \left[g_r^{\uparrow\downarrow} \widehat{S}_M \times \left(\widehat{s} \times \widehat{S}_M \right) + g_i^{\uparrow\downarrow} \widehat{S}_M \times \widehat{s} \right]$$

with $g^{\uparrow\downarrow} = 1 - (t_{\uparrow\uparrow} t_{\downarrow\downarrow}^* + r_{\uparrow\uparrow} r_{\downarrow\downarrow}^*)$, the spin mixing coefficient



Notes:

 $T = 0 \text{ if } t_{\uparrow} = t_{\Downarrow} \text{ and } r_{\uparrow} = r_{\Downarrow} \text{ (no spin filtering)} \qquad (\text{Note: } |t_{\uparrow(\Downarrow)}^2| + |r_{\uparrow(\Downarrow)}^2| = 1)$ $T = 0 \text{ if } \theta = 0 \text{ or } \theta = \pi \text{ (collinearity)}$

The above formula considered T created by one type of electron wave only. T_{total} can be obtained by summation over the Fermi surface of the N layer corresponding to all possible incident wave vectors.

Reflected (dephased) spins affect spin accumulation, e. g. resulting in \frown a non-trivial θ -dependence of STT).



In metallic structures, some transverse components average out: $\mathcal{R}e(t_{\uparrow}t_{\downarrow}^{*}) = \Im(t_{\uparrow}t_{\downarrow}^{*}) \approx 0$ and $\Im(r_{\uparrow}r_{\downarrow}^{*}) \ll \mathcal{R}e(t_{\uparrow}t_{\downarrow}^{*} + r_{\uparrow}r_{\downarrow}^{*})$. The FL term is small (less than 5% of the DL). This contrasts with tunnel junctions, where the *k*-selection upon tunnelling reduces the effect of averaging (FL ~ 30% of DL).

 $R_{\perp} = \mathcal{R}e(r_{\uparrow\uparrow}r_{\downarrow\uparrow}^*)$ and $R_{\times} = \Im m(r_{\uparrow\uparrow}r_{\downarrow\downarrow}^*)$ describe reflection along axes transverse to S_M . They are called the transverse reflection coefficients or spin-mixing coefficients.

3. The STT term in diffusion equations



Charge conservation:

 ∇ . Je = 0

Total angular momentum conservation:

any loss in spin current must be due to spin-flips (1st term) or to spin transfer torque i. e. precession of the spin accumulation around the local magnetization due to *s*–*d* exchange interaction (2nd term).

$$\nabla \cdot \boldsymbol{J}_{\boldsymbol{s}} = \frac{\sigma^* (1 - \beta^2)}{4e l_{sf}^{*2}} \boldsymbol{\mu}_{\boldsymbol{s}} + \frac{\sigma^*}{4e M_s l_{sd}^2} (\boldsymbol{M} \times \boldsymbol{\mu}_{\boldsymbol{s}})$$

 l_{sf}^* is the average spin-diffusion length defined in lecture 2 $l_{sd} = \sqrt{2D\hbar/J_{sd}}$ is the 'exchange' spin-reorientation length, i. e. the distance over which the spin polarization is reoriented along M(typically, $l_{sd} \sim 1 nm$ in metals) Typical critical current densities for switching magnetization by STT are $J_{e,crit} \sim 10^7 A. cm^{-2}$, hence the need for nm lateral dimensions (in addition to nm-thick layers due to l_{sf}^* and l_{sd})



3. The STT term in diffusion equations



For a positive electron flux $(J_{e,crit}^{-})$, spins travel only once across the N (Cu) layer.

For a negative electron flux $(J_{e,crit}^+)$, spins travel twice across the N (Cu) layer.



4. The STT term in magnetization dynamics equations

Dompy Lot Di 181 Martin Martin St Introducing the STT DL term in the LLG equation: JM = - 18/T - 18/T Dom dampint * (m × M) + 18/ 2FZ Ng





$$\frac{dM}{dt} = -|\gamma|M \times \left(\mu_0 H_{eff}\right) + \frac{\alpha}{M_S}M \times \frac{dM}{dt} + |\gamma|\frac{\tau_{DL}}{M_S^2}M \times (m \times M) + \frac{\tau_D}{T} \text{ with } \tau_{DL} = \frac{J_e\hbar\beta}{2eM_Sd_F}$$

Estimating the critical current density, stability criterion (with H=0, H_k~0):

$$|\gamma|\tau_{DL,crit} = 2\pi \frac{\alpha}{dt} = 2\pi \alpha f \Rightarrow |\gamma| \frac{J_e \hbar \beta}{2eM_S d_F} = 2\pi \frac{|\gamma|\mu_0 M_S}{2}$$

$$J_{e,crit} = \frac{e\mu_0 M_S^2 d_F \alpha}{\hbar \beta}$$

For permalloy (Ni₈₀Fe₂₀): $\alpha = 0.008$, M_S = 0.8 MA. m⁻¹, g=2.1, P=0.3. Let's consider: d_F = 3 nm, $\Rightarrow J_{e,crit} \sim 1 \times 10^7$ A. cm⁻²

6. STT - spin pumping reciprocity

STT has another reciprocal effect called spin pumping

Spin transfer torque J_s puts M into motion



Spin pumping The motion of M induces J_s



DOI: 10.1051/978-2-7598-2917-0.c002

6. STT - spin pumping reciprocity



$$J_{s}^{0} = J_{s}^{pump} - J_{s}^{back} = \frac{e}{2\pi M_{s}^{2}} \mathcal{R}e(g_{eff}^{\uparrow\downarrow})M \times \frac{dM}{dt} + \frac{e}{2\pi M_{s}} \mathfrak{I}m(g_{eff}^{\uparrow\downarrow})\frac{dM}{dt}$$

cf. Exercice 2

7. STT in magnetic textures

Spin transfer torque also exists in magnetic textures like domain walls (DWs):

- when the moments of the itinerant *s*-electrons (m in the sketch below) follow adiabatically the magnetization (M), then $\nabla \cdot J_s \propto \nabla \cdot M$ builds ups. This gives rise to an 'adiabatic' contribution to STT.
- when the spins are unable to follow *M* (spin-mistracking), then spin accumulation builds up, giving rise to a 'non-adiabatic' contribution.



$$-T = \frac{\hbar\beta}{2eM_{S}^{3}(1+\xi^{2})}M \times [M \times (J_{e} \cdot \nabla)M] + \frac{\hbar\beta\xi}{2eM_{S}^{2}(1+\xi^{2})}M \times (J_{e} \cdot \nabla)M$$
DL
FL
Adiabatic
FL
Non-adiabatic

7. STT in magnetic textures

- Spin transfer torque can also be efficient to move magnetic textures.



 $\xi \ll 1$ in weakly SO-coupled dense-moment F metals, e. g. (Co) => DL \gg FL $\xi \gg 1$ in strongly SO-coupled dilute-moment F semiconductors, e. g. (Ga,Mn)As => FL \gg DL

7. STT in magnetic textures

- Possible application of STT in magnetic textures: the racetrack memory.



8. Conclusion

- Spin transfer torque - STT

- sd coupling between spin accumulation and magnetization
- Damping-like vs field-like contributions
- Quantum mechanical model
- STT in diffusion equation of transport
 - Loss of spin current = spin-flips + STT
 - Critical currents for switching: $J_e^{P \to AP} > J_e^{AP \to P}$
- STT in magnetization dynamics equations
 - Precession vs switching
 - Magnetic textures

- References:

- D. E. Bürgler **D3**, in S. Blügel *et al* (eds) Spintronics from GMR to quantum information (2009) Tutorial articles: D. C. Ralph & M. D. Stiles, JMMM **320**, 1190 (2008); M. D. Stiles & J. Miltat, Topics in Appl. Phys. **101**, 225 (2006); and references therein
- Models: J. C. Slonczewski, JMMM **159**, L1 (1996); L. Berger, Phys. Rev. B **54**, 9353 (1996)
- Experiments: J. Katine et al, Phys. Rev. Lett. 84, 3149 (2000); W. H. Rippard et al, ibid 92, 027201 (2004)
- STT in transport: N. Strelkov et al, Phys. Rev. B 84, 024416 (2011)
- Spin pumping: Y. Tserkovnyak et al, Rev. Mod. Phys. 77, 1375 (2005)
- STT in DWs: S. Zhang & Z. Li , Phys. Rev. Lett. **93**, 127204 (2004)
- Racetrack memory: S. S. P. Parkin et al, Science **320**, 190 (2008)

Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	_	04 Dec
Lecture 2	-	07 Dec
Lecture 3	-	11 Dec
Lecture 4	-	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/

- I. Brief overview of the field of spintronics and its applications
- II. First notions to describe electron and spin transport AMR, CIP-GMR

- $1h^{30}$ IV. Transfer of angular momentum STT
 - V. Berry curvature, parity and time symmetries AHE
 - VI. Brief non-exhaustive introduction to current topics

Exercise 1 - Anisotropic magnetoresistance (AMR)
 Exercise 2 – The spin pumping (SP) and inverse spin Hall effects (ISHE)

1h30

Th

V. Berry curvature, parity and time symmetries – AHE

1. The Hall effect trio



 $J_{e} = \overline{\overline{O}}, E = \begin{pmatrix} \overline{O}_{xy} & \overline{O}_{yy} & 0 \\ -\overline{O}_{xy} & \overline{O}_{yy} & 0 \\ 0 & 0 & 0 \end{pmatrix} E$



(Ordinary) Hall effect



Change of momentum

tk=-eF-en

$$\rho_{xy} = \mathrm{R}_{0}\mathrm{H}_{\mathrm{Z}} = -\frac{1}{\mathrm{ne}}\mathrm{H}_{\mathrm{Z}}$$

In symmetry words: 1. *B* breaks the time reversal (\mathcal{T})symmetry of the system 2. the Lorentz force connects electrons to \mathcal{T} -breaking¹

$$\rho_{xy}(\boldsymbol{r}) = -\rho_{xy}(-\boldsymbol{r})$$

V. Berry curvature, parity and time symmetries – AHE 1. The Hall effect trio



Master 2 N2 UGA - lecture Baltz, V

Anomalous Hall effect Intrinsic origin



PKy = R No 17

In symmetry words: 1. M_Z breaks the time reversal (\mathcal{T})symmetry of the system 2. the spin-orbit coupling connects electrons to \mathcal{T} -breaking

$$\rho_{xy}(\boldsymbol{r}) = -\rho_{xy}(-\boldsymbol{r})$$

More generally, Change of position

Master 2 N2 UGA - lecture Baltz, V

105

V. Berry curvature, parity and time symmetries – AHE

2. The Berry curvature

$$\boldsymbol{v}_{n}(\boldsymbol{k}) = \frac{\partial \varepsilon_{n}(\boldsymbol{k})}{\hbar \partial \boldsymbol{k}} - \frac{\dot{\boldsymbol{k}} \times \boldsymbol{\Omega}_{n}(\boldsymbol{k})}{\text{Transversal velocity}}$$
Berry curvature

Electonic transport in a material under an external potential gradient is calculated from the Schrödinger equation:

Energy band dispersion energy eigenvalues

Berry curvature dispersion from Bloch wavefunction eigenstates

 $\mathcal{E}_{\mathbf{h}}(\mathbf{k}(F))$

k(t) gauge invariant crystal momentum, includes the time varying external potential in the electron frame

'A uniform *E* means that V(r) varies linearly in space and breaks the translational symmetry of the crystal so that Bloch's theorem cannot be applied. To avoid this difficulty, one can let the electric field enter through a uniform vector potential A(t) that changes in time.'

Master 2 N2 UGA - lecture Baltz, V

The Berry formalism stems from the adiabatic theorem in quantum mechanics: a physical system remains in its instantaneous eigenstate, up to a phase throughout the process of a cyclic evolution, if a given perturbation is acting on it slowly enough.



Master 2 N2 UGA - lecture Baltz, V

$$\begin{aligned} \mathcal{H}|\psi_{n}(\boldsymbol{k})\rangle &= \varepsilon_{n}(\boldsymbol{k})|\psi_{n}(\boldsymbol{k})\rangle\\ e^{i\varphi}|\psi_{n}(\boldsymbol{k})\rangle; \varepsilon_{n}(\boldsymbol{k})\\ \varphi &= \varphi^{geo.}(\boldsymbol{k}) + \varphi^{dyn.}(\varepsilon_{n}) \end{aligned}$$

Dynamic phase:

 $\varphi^{dyn.}(\varepsilon_n)$

Usual phase that appears even for a time independent Hamiltonian. It addresses the following question: how long did the journey last ?



Geometric (Berry) phase:

Phase related to variations of k and only dependent on the trajectory of this parameter. It addresses the following question:
2. The Berry curvature

Geometric (Berry) phase:

only dependent on the trajectory of this parameter. It addresses the following question: which way did the system go during the journey ?

 $\varphi^{geo.}(\boldsymbol{k}) = \gamma_n(\boldsymbol{k})$

Simple example of parallel transport on a closed contour C



Master 2 N2 UGA - lecture Baltz, V

Geometric (Berry) phase:

only dependent on the trajectory of this parameter. It addresses the following question: which way did the system go during the journey ?

 $\varphi^{geo.}(\boldsymbol{k}) = \gamma_n(\boldsymbol{k})$

General formalism for parallel transport on a closed contour C



Rotation of **a**, **b** by: φ^{geo} . $af = a_i \cos \varphi^{3eo} - b_i \sin \varphi^{3eo}$ $bf = a_i \sin \varphi^{3eo} + b_i \cos \varphi^{3eo}$ $G_{n,i} der U_i = a_i + ib_i$ $O_{ne} obtain U_e = a_i + ib_i = e^i \varphi^{3eo}$ $Q_{ne} = a_i + ib_i = a_i + ib_i = e^i \varphi^{3eo}$

 $\varphi^{geo.}(\mathcal{C})$ is the solid angle subtended by \mathcal{C}

Adapted from Jean Dalibard's lecture www.college-de-france.fr

'It is now well recognized that information on the Berry curvature is essential in a proper description of the dynamics of Bloch electrons, which has various effects on transport and thermodynamic properties of crystals.'

 $\mathcal{H}|\psi_n(\boldsymbol{k})\rangle = \varepsilon_n(\boldsymbol{k})|\psi_n(\boldsymbol{k})\rangle$

 $e^{i\gamma_n(\mathbf{k})}|\psi_n(\mathbf{k})\rangle$

Berry phase	$\gamma_n(\mathbf{k}) = \oint \mathcal{A}_n(\mathbf{k}) d\mathbf{k} = \iint \Omega_n(\mathbf{k}) d^2 \mathbf{k}$	Global
Berry connection	$\mathcal{A}_{n}(\boldsymbol{k}) = \langle \psi_{n}(\boldsymbol{k}) i \nabla_{\boldsymbol{k}} \psi_{n}(\boldsymbol{k}) \rangle$	
Berry curvature	$\Omega_n(\mathbf{k}) = \nabla_{\mathbf{k}} \times \langle \psi_n(\mathbf{k}) i \nabla_{\mathbf{k}} \psi_n(\mathbf{k}) \rangle$	Local



V. Berry curvature, parity and time symmetries – AHE

2. The Berry curvature

system dimension Semiclassical transport theory $J_{e} = -e^{\sum_{n}} (\mathbf{v}_{n}(\mathbf{k})) \frac{d^{n}\mathbf{k}}{(2\pi)^{n}}$ $\boldsymbol{v}_n(\boldsymbol{k}) = \frac{\partial \varepsilon_n(\boldsymbol{k})}{\hbar \partial \boldsymbol{k}} - \dot{\boldsymbol{k}} \times \boldsymbol{\Omega}_n(\boldsymbol{k})$ $g(\varepsilon_n) = f(\varepsilon_n) + \delta g(\varepsilon_n)$ $\dot{k} = -\frac{e}{k}E$ $\mathcal{J}_{e} = \overline{\mathcal{O}} \cdot \overline{\mathcal{E}} = \begin{pmatrix} \delta_{x} & \delta_{y} \\ -\delta_{x} & \delta_{y} \\ -\delta_{x} & \delta_{y} \\ -\delta_{x} & \delta_{y} \end{pmatrix}$

$\sigma_{xy} (S. cm^{-1})$	bcc Fe	fcc Ni	hcp Co
Fermi loop	750	-2275	478
Fermi loop (first term)	7	0	-4
Berry curvature	753	-2203	477
Previous theory	751 ^a	-2073 ^b	492 ^b
Expt.	1032 ^c	-646 ^d	480 ^e

Phys. Rev. B 76, 195109 (2007)

Ab initio calculations



Figure 15. Left: band structure of bulk Fe near Fermi energy (upper panel) and Berry curvature $\Omega^{z}(\mathbf{k})$ (lower panel) along symmetry lines. Right: Fermi surface in (010) plane (solid lines) and Berry curvature $-\Omega^{z}(\mathbf{k})$ in atomic units (color map). Reproduced with permission from [41]. Copyright 2004 American Physical Society.

Ab initio calculations



V. Berry curvature, parity and time symmetries – AHE 2. The Berry curvature

Electron number of 4d and 5d metals Metals (Ry) Structure $5(4d^45s^1)$ Nb 0.006 bcc $6(4d^55s^1)$ 0.007 Mo bcc 7 $(4d^65s^1)$ 0.009 Tc hcp $8 (4d^75s^1)$ 0.01 hcp Ru $\gamma = 0.2$ 0.05 9 $(4d^85s^1)$ SHC (10³Ω⁻¹cm⁻¹) 0.011 Rh fcc $10 (4d^{10}5s^0)$ Pd fcc 0.013 11 $(4d^{10}5s^1)$ 0.019 fcc Ag 0.0 $5(5d^36s^2)$ 0.023 Ta bcc $6(5d^46s^2)$ W 0.027 bcc $7(5d^56s^2)$ Re hcp 0.025 $8(5d^66s^2)$ -0.05 hcp 0.025 Os -5d 9 $(5d^96s^0)$ Ir fcc 0.025 $10 (5d^96s^1)$ fcc 0.03 Pt Phys. Rev. B 77, 165117 (2008) 11 $(5d^{10}6s^1)$ 0.03 Au fcc -0.110 11 8 5 6 7 9 n Tc 4d Nb Mo Ru Rh Ag Pd $\sigma_{xy}^{z} (10^{2} \Omega^{-1} cm^{-1})$ -20 5d Ta Ir Pt Au W Re Os 6 Pt, Au 0 Lett. 100, 096401 (2008) Ta. W 20 -: -: -: -: 4 N ω ം ப் ப் ப் \circ ά -, e خ Energy (eV) Master 2 N2 UGA - lecture Baltz, V

The intrinsic spin Hall conductivity

SOI

$$\sigma_{xy} = \frac{e^2}{\hbar} \sum_{n} \frac{d^d \mathbf{k}}{(2\pi)^{d-1}} \int \boldsymbol{\Omega}_n(\mathbf{k}) f(\varepsilon_n(\mathbf{k})) d^d \mathbf{k}$$

This is the 'unquantized' version of the Hall effect for a system in *d* dimension.



A whole family of Hall effects, beyond the Hall trio:



Nobel Prizes related to QHE:

1980	K. Von Klitzing	QHE
1998	H. Störmer, D. Tsui, R. Laughlin	Fractional QHE
2010	A. Geim, K. Novoselov	Graphene
2016	D. J. Thouless, F. D. M. Haldane, J. M. Kosterlitz	Topological insulator

Von Klitzing constant : $\mathbf{R}_{\kappa} = \mathbf{h}/\mathbf{e}^2$ depends only on physical constants

More stable and reproducible than any other resistance (25812.807 Ohm)

SiCsubstrate/Graphene = QHE new standard QHE key to the new definition of units in 2018



4. Parity and time symmetries

Intrinsic origin relates to the Bloch states – Berry curvature

Master 2 N2 UGA - lecture Baltz, V

J

F

Intrinsic origin relates to the Bloch states – Berry curvature

$$\boldsymbol{v}_{n}(\boldsymbol{k}) = \frac{\partial \varepsilon_{n}(\boldsymbol{k})}{\hbar \partial \boldsymbol{k}} - \dot{\boldsymbol{k}} \times \boldsymbol{\Omega}_{n}(\boldsymbol{k})$$

Transversal velocity

$$\sigma_{xy} = \frac{e^2}{\hbar} \sum_{n} \frac{d^d \mathbf{k}}{(2\pi)^{d-1}} \int \mathbf{\Omega}_n(\mathbf{k}) f(\varepsilon_n(\mathbf{k})) d^d \mathbf{k}$$

Non-zero Ω_n requires breaking of time-reversal (\mathcal{T}) or spatial inversion (\mathcal{P}) symmetry

$$\mathcal{P} \qquad \mathcal{T} \qquad \mathcal{P}\mathcal{T}$$
$$\Omega(-k) = \Omega(k) + \quad \Omega(-k) = -\Omega(k) \qquad \longrightarrow \qquad \Omega(k) = -\Omega(k) = 0$$

Such type of Hall effect therefore exists even if $M_z = 0$ spin Hall effect in general, ρ_{xy}^z see also anomalous Hall in antiferromagnets, $\rho_{xy} = R_0 H_Z + R_S M_Z + \rho_{xy}^{AF}$

4. Parity and time symmetries

Spontaneous Hall effect in antiferromagnets even if $M_z = 0$?

 \rightarrow **Yes**! The key is breaking of \mathcal{T} -symmetry

Breaking \mathcal{T} -symmetry

Non-zero Berry curvature

Intrinsic Hall effect

$$\rho_{xy} = R_0 H_Z + R_S M_Z + \rho_{xy}^{AF}$$

М





arXiv:2012.15651

Master 2 N2 UGA - lecture Baltz, V

V. Berry curvature, parity and time symmetries – AHE

4. Parity and time symmetries



V. Berry curvature, parity and time symmetries – AHE

4. Parity and time symmetries



Note: beware the color code, when blue/red is commonly used to distinguish majority and minority-spin bands (see slide 123), it is also commonly used to distinguish the upper/lower band, no matter spin (see slide 124).

Slide 124:

 Ω_z : the Berry curvature is non-zero around the gap and non-zero curvatures required combining Rashba (λ) and Zeeman (Δ) contributions. It has the same form as the Berry curvature in one valley of graphene.

 σ_{xy} : for $\varepsilon_{\rm F} < -\Delta$ the Hall conductivity first increases when increasing the Fermi energy, as one integrates the contribution to the Berry curvature of the lower band. In the gap (for $-\Delta < \varepsilon_{\rm F} < \Delta$), the Hall conductivity saturates as the lower band fully contributed. Above the gap (for $\varepsilon_{\rm F} > \Delta$), the Hall conductivity reduces as one integrates the contribution to the Berry curvature of the upper band which opposes that of the lower band.

Thermal (Nernst) counterparts to electrical Hall effects



V. Berry curvature, parity and time symmetries – AHE

5. Supplemental information

Extrinsic contributions to the Hall effects



- Berry curvature

- cyclic adiabatic evolution
- describes the dynamics of Bloch electrons (in a periodic crystal structure)
- has various effects on transport and thermodynamic properties of crystals
- Anomalous Hall effect
 - Intrinsic contribution: requires breaking of the \mathcal{PT} combination example of spin polarized 2D electron gas with Rashba SO coupling
 - Extrinsic contribution: due to spin-dependent scattering (skew and side jump)

- \mathcal{P} and \mathcal{T} symmetries

- Bulk contribution: relates to group theory
- Structure contribution: example of the Rashba interface effect

- References:

-]	Berry curvature:	D. Xiao <i>et al,</i> Rev. Mod. Phys. 82 , 1959 (2010)	
		Jean Dalibard's lecture, <u>www.college-de-france.fr</u>	
-	Hall effects family:	N. Nagaosa <i>et al,</i> Rev. Mod. Phys. 82 , 1539 (2010)	
		H. Weng <i>et al,</i> A-APPS Bulletin 23 , 3 (2013)	
		K. von Klitzing <i>et al,</i> Nat. Rev. Phys. 2 , 397 (2020)	
-	Rashba effect:	A. Manchon <i>et al,</i> Nat. Mater. 14 , 871 (2015)	

VI. Brief non-exhaustive introduction to current topics

VI. Brief non-exhaustive introduction to current topics

1. Applied targets and basic research topics

Intended applications: Spin Memories Spin Transistors Information technology-IT (e.g. memory, processors, data security) Biomedical (e.g. sensors) Quantum spintronics -**3rd Generation** Spin interference "3D and quantum" 3D structures Telecommunication-T (e.g. transceiver) Spin operation 2nd Generation Spin resonance "Spin dynamics" Spin damping Artificial intelligence-AI (e.g. neuromorphic computing) Spin transfer **1st Generation** Spin accumulation "Spin transport" Spin injection / detection **Spintronics**



Among current research topics:

- Symmetry, topology [1,2]
- Transfer of angular momentum: electron, phonon, photon [2-6]
- Ultimate time scales [3,4,6]
- 'New' materials / structures / instrumentation [6-9]
- Quantum spintronics
- Mature fields: MRAM/Design (IT), Sensors (IT, Bio), Oscillators (T, AI) [7]

VI. Brief non-exhaustive introduction to current topics

2. For further reading



Complete slides posted online on the UGA Moodle platform



More on electron transport in spintronics:

magnetoelectronic circuit theory spin-orbit torques skyrmion Hall angle spin Hall magnetoresistance intrinsic and extrinsic damping anomalous Hall harmonic analysis

https://bit.ly/3oScD5p

...



Lectures on spintronics

Master 2 Univ. Grenoble Alpes

Vincent Baltz CNRS Researcher at SPINTEC

Lecture 1	—	04 Dec
Lecture 2	-	07 Dec
Lecture 3	_	11 Dec
Lecture 4	-	14 Dec
Exercises 1 & 2	_	21 Dec



vincent.baltz@cea.fr https://fr.linkedin.com/in/vincentbaltz www.spintec.fr/af-spintronics/

- I. Brief overview of the field of spintronics and its applications
- II. First notions to describe electron and spin transport AMR, CIP-GMR

$$\sqrt{10^{30}}$$
 III. Spin accumulation – CPP-GMR

- 10^{30} IV. Transfer of angular momentum STT
 - V. Berry curvature, parity and time symmetries AHE
 - VI. Brief non-exhaustive introduction to current topics

Exercise 1 - Anisotropic magnetoresistance (AMR)

Exercise 2 – The spin pumping (SP) and inverse spin Hall effects (ISHE)

1h30

1h30

1h30

Exercises 1 & 2

1. Anisotropic magnetoresistance (AMR)

Introduction / Reminder

The anisotropic magnetoresistance (AMR) effect refers to the dependence of the electrical resistivity ρ on the relative angle θ between the applied electrical current I and the magnetization M of a magnetic material [W. Thomson, Proc. Roy. Soc. 8, 546 (1857); T. McGuire and R. Potter, IEEE Trans.Magn. 11, 1018 (1975)]. It is a bulk property caused by anisotropic mixing of majority moment(\uparrow)-spin(\Downarrow) electrons and minority moment(\downarrow)-spin(\Uparrow) electrons conduction bands, induced by the spin-orbit interaction.

In the reference frame set by **M** (FIG. 1), the electric field **E** and the current density J_e are linked by the resistivity tensor $\bar{\rho}$

$$\boldsymbol{E} = \bar{\rho} \boldsymbol{J}_{\boldsymbol{e}}$$
with $\begin{pmatrix} E_{\parallel} \\ E_{\perp} \end{pmatrix} = \begin{pmatrix} \rho_{\parallel} & 0 \\ 0 & \rho_{\perp} \end{pmatrix} \begin{pmatrix} J_{\parallel} \\ J_{\perp} \end{pmatrix}$
(1)

with ρ_{\parallel} and ρ_{\perp} , the resistivities for $J_e \parallel M$ and $J_e \perp M$, respectively.

Questions

a) Find the expressions of E_x and E_y vs. J_x , J_y , ρ_{\parallel} , ρ_{\perp} and θ , in the experimental reference frame defined by (\hat{x}, \hat{y}) , (FIG. 1).



FIG. 1. Illustration showing the two reference frames considered.

- b) In practice, how would you proceed experimentally to measure ρ_{\parallel} and ρ_{\perp} ? What is the order of magnitude of the values of field, current, voltage etc that you think you would use or measure?
- c) Experimental measurements of Ni films at room temperature returned $\rho_{\parallel} = 8.2 \ \mu\Omega.cm$ and $\rho_{\perp} = 8 \ \mu\Omega.cm$. Calculate the AMR ratio $\frac{\Delta\rho}{\rho} = \frac{\rho_{\parallel} - \rho_{\perp}}{\rho_{\perp}}$ for Ni. Can you think of any practical use of the AMR effect ?

d) We now consider a 'Union Jack' device shown in FIG. 2, a magnetization pointing along \hat{x} , a film of thickness d, and a time-dependent square wave current density $J_{ij}(t)$. Plot the time(t)-variation of: V_{15} , and V_{37} for J_{15} ; V_{84} , and V_{26} for J_{84} ; V_{73} , and V_{15} for J_{73} ; V_{62} , and V_{84} for J_{62} .



FIG. 2. Illustration of the 'Union Jack' device considered.

e) An antiferromagnet is used instead of a ferromagnet. This antiferromagnet has two collinear sublattices with magnetizations pointing towards opposite directions (M_1 =- M_2). The total magnetization is $M=M_1+M_2=0$. Do you think that using AMR is appropriate to characterize this type of magnetic material ?

2. Spin pumping (SP) and inverse spin Hall effect (ISHE)

Introduction / Reminder

The spin pumping effect [Y. Tserkovnyak *et al*, Rev. Mod. Phys. **77**, 1375 (2005)] refers to the ability of a magnetic material to generate a spin *s* current J_s^0 when brought out-of-equilibrium. The technique usually involves inducing resonance in a ferromagnetic (F) spin injector – *e.g.* a NiFe layer – which is adjacent to a non-magnetic material (N) known as the spin sink – *e.g.* a Pt layer (FIG. 3). Spin pumping and spin transfer torque are reciprocal effect. An intuitive picture consists in comparing spin transfer torque to a water flow (spin current) moving the blades of a watermill (magnetization) and spin pumping to moving blades (magnetization) creating a water flow (spin current).



FIG. 3. (a) Illustration of the spin pumping effect due to sustained out-of-equilibrium magnetization dynamics. (b) Illustration of spin current diffusion across the non-magnetic layer (here, Pt). (c) Equivalent circuit considering spin-charge conversion due to the inverse spin Hall effect in the non-magnetic layer. Adapted from K. Ando *et al*, J. Appl. Phys. **109**, 103913 (2011).

Questions

- a) Because the system is out-of-equilibrium, spins accumulate at the F/N interface and diffuse across the N layer [FIG. 3(b)]. The time-varying spin density (nonequilibrium chemical-potential imbalance) can be written as follows: $\tilde{\mu_s} = \mu_s e^{i\omega t}$. In this part, you will calculate the y-dependence of the spin current in the N layer: $J_s(y)$.
 - a1) Write the relation between J_s and μ_s . This will be Eq. (a1).
 - a2) Write the transport equation that regulates μ_s and show that $\frac{d^2\mu_s}{dy^2} - \frac{1}{l_{ef}^{\# 2}} \mu_s = 0,$ (a2)

with $l_{sf}^{\#} = \frac{l_{sf}^{*}}{\sqrt{1+i\omega\tau_{sf}^{*}}}$ and $l_{sf}^{*} = \sqrt{D\tau_{sf}^{*}}$, where *D* is the diffusive constant, and τ_{sf}^{*} is the average spin flip scattering rate in the N layer. Here, $l_{sf}^{*} = l_{sf,N}^{*}$ and $l_{sf}^{\#} = l_{sf,N}^{\#}$.

- a3) Is it realistic to consider that $l_{sf}^{\#} \sim l_{sf}^{*}$?
- a4) Write the boundary conditions at y = 0 and $y = d_N$.
- a5) Use the result of question a4) and the fact that the solution of Eq. (a2) takes the following form: $\mu_s(y) = Ae^{y/l_{sf}^*} + Be^{-y/l_{sf}^*}$, to explicit $\mu_s(y)$ vs y, d_N , l_{sf}^* , e, and ρ_N .
- a6) Use the result of question a5) and Eq. (a1) to explicit $J_s(y)$ vs y, d_N , l_{sf}^* , and J_s^0 . This will be Eq. (a6).
- b) Due to the inverse spin Hall effect (ISHE) (§V), the spin current is converted in a transverse charge current J_e along x. The N layer then becomes a 'source' of charge current. The spin-charge conversion is expressed as $J_e(y) = \theta_{SHE}J_s(y)$, where θ_{SHE} is called the spin Hall angle.
 - b1) Use Eq. (a6) and the indications above to explicit the average charge current density $J_e = \langle J_e(y) \rangle = \frac{1}{d_N} \int_0^{d_N} J_e(y) dy$ vs y, d_N , l_{sf} , and J_s^0 .
 - b2) Plot the charge current *I* vs d_N . Comment the trend for $d_N \ll l_{sf}^*$ and for $d_N \gg l_{sf}^*$.
 - b3) The equivalent circuit of the F/N bilayer is illustrated in FIG. 3(c). Explicit the electromotive force (voltage V_{ISHE}) due to the inverse spin Hall effect in the N layer induced by spin pumping in a F/N bilayer.
 - b4) Calculate the value of the 'spin-charge conversion efficiency': $\theta_{SHE} l_{sf}^*$, considering that $d_N \sigma_N \gg d_F \sigma_F$, and for V_{ISHE} =4 μV , d_N =10 nm, l_{sf}^* =3 nm, σ_N =4 x 10⁶ S.m⁻¹, w=0.5 mm, and J_s^0 =4.8 x 10⁵ A.m⁻².
 - b5) A contribution to the spin Hall angle is due to extrinsic sd scattering on defects. Given this specific contribution – intrinsic contributions are not considered here - how would you proceed to increase the value of the spin Hall angle in a material ? Will the options you propose improve the 'spin-charge conversion efficiency' ?
- c) It is possible to show that the angular dependence of the inverse spin Hall voltage is

$$V_{ISHE} = \frac{w\theta_{SHE} l_{sf}^* \tanh\left(d_N/(2l_{sf}^*)\right)}{d_N \sigma_N + d_F \sigma_F} \frac{eg_r^{\uparrow\downarrow} \gamma^2 (\mu_0 h_{rf})^2}{8\pi \alpha^2 \omega} \sin(\theta_M) \,\overline{\Gamma},\tag{c}$$

with $\overline{\Gamma} = 2\omega \frac{\mu_0 M_S |\gamma| \sin^2(\theta_M) + \sqrt{(\mu_0 M_S \gamma \sin^2(\theta_M))^2 + 4\omega^2}}{(\mu_0 M_S \gamma \sin^2(\theta_M))^2 + 4\omega^2}$, w the width of the layers, θ_{SHE} the spin-Hall angle, h_{rf} the *rf* excitation field used to reach F resonance, and ω the resonance angular frequency. θ_M is defined in FIG. 4. $\overline{\Gamma}$ is a parameter accounting for the trajectory of the magnetization precession in the (xy) plane. It can be viewed as the elliptic- to circular-trajectory ratio. $g_r^{\uparrow\downarrow}$ is the real part of the spin mixing conductance per unit area per quantum conductance per spin channel, accounting for the ability of the F/N interface and N layer to absorb the spin component along $M \times (m \times M)$.

- c1) Show that $\overline{\Gamma}$ is a dimensionless parameter.
- c2) What is the trajectory of the magnetization precession for θ_M =0 ? Why is it so ? And should it always be the case ?
- c3) The angular(θ_H)-dependence of the magnetization's tilt θ_M deduced from experimental data for the case of a 8 nm-thick NiFe film is given in FIG. 4. θ_H is the angle between the applied magnetic field **H** and the normal to the sample's surface **y**. Comment this behaviour: what governs it ? Use Eq. (c) and FIG. 4, to hand-sketch the θ_H -dependence of V_{ISHE} . Comment the symmetry of V_{ISHE} with **H**.



FIG. 4. Typical angular(θ_H)-dependence of the magnetization's tilt θ_M . From O. Gladii *et al*, Phys. Rev. B **100**, 174409 (2019).

Solutions to exercise 1

a) A change of basis can be done by using the appropriate rotation matrix

$$\begin{pmatrix} E_{\parallel} \\ E_{\perp} \end{pmatrix} = \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} E_{x} \\ E_{y} \end{pmatrix} \text{ and } \begin{pmatrix} J_{\parallel} \\ J_{\perp} \end{pmatrix} = \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} J_{x} \\ J_{y} \end{pmatrix}$$
(2)

Combining Eqs. (1) (see text of exercise 1) and (2) gives

$$\begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} E_x \\ E_y \end{pmatrix} = \begin{pmatrix} \rho_{\parallel} & 0 \\ 0 & \rho_{\perp} \end{pmatrix} \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix},$$

$$\begin{pmatrix} E_x \\ E_y \end{pmatrix} = \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix}^{-1} \begin{pmatrix} \rho_{\parallel} & 0 \\ 0 & \rho_{\perp} \end{pmatrix} \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix},$$

$$\begin{pmatrix} E_x \\ E_y \end{pmatrix} = \frac{1}{\cos^2\theta + \sin^2\theta} \begin{pmatrix} \cos\theta & -\sin\theta \\ \sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} \rho_{\parallel} & 0 \\ 0 & \rho_{\perp} \end{pmatrix} \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix},$$

$$\begin{pmatrix} E_x \\ E_y \end{pmatrix} = \begin{pmatrix} \cos\theta \rho_{\parallel} & -\sin\theta \rho_{\perp} \\ \sin\theta \rho_{\parallel} & \cos\theta \rho_{\perp} \end{pmatrix} \begin{pmatrix} \cos\theta & \sin\theta \\ -\sin\theta & \cos\theta \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix},$$

$$\begin{pmatrix} E_x \\ E_y \end{pmatrix} = \begin{pmatrix} \cos^2\theta \rho_{\parallel} + \sin^2\theta \rho_{\perp} & \cos\theta \sin\theta & (\rho_{\parallel} - \rho_{\perp}) \\ \cos\theta & \sin\theta & (\rho_{\parallel} - \rho_{\perp}) & \sin^2\theta \rho_{\parallel} + \cos^2\theta \rho_{\perp} \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix},$$

$$\begin{pmatrix} E_x \\ E_y \end{pmatrix} = \begin{pmatrix} \rho_{\parallel} - (\rho_{\parallel} - \rho_{\perp}) \sin^2 \theta & \cos \theta \sin \theta (\rho_{\parallel} - \rho_{\perp}) \\ \cos \theta \sin \theta (\rho_{\parallel} - \rho_{\perp}) & \rho_{\perp} - (\rho_{\perp} - \rho_{\parallel}) \sin^2 \theta \end{pmatrix} \begin{pmatrix} J_x \\ J_y \end{pmatrix}$$
(3)

For $J_y = 0$, we obtain

$$E_x = [\rho_{\parallel} - (\rho_{\parallel} - \rho_{\perp}) \sin^2 \theta] J_x,$$
$$E_y = (\rho_{\parallel} - \rho_{\perp}) \cos \theta \sin \theta J_x.$$

Note that, in this case, a transversal voltage drop $\propto E_y$ is obtained when $\theta \neq 0$ and $\theta \neq \pi/2$. By analogy, this effect is called the planar Hall effect. It is noteworthy that the terminology planar Hall effect is misleading because the phenomenon at play is unrelated to Hall effects. The terminology transverse AMR is sometimes preferred.

b) Use 4-point resistance measurements and a known geometry [I. Miccoli *et al*, J. Phys. Cond. Mat. **27**, 223201 (2015)].

Set $I_x \neq 0$ and $I_y = 0$.

Monitor V_{χ} , to get R_{χ} .

Use a magnet to apply an external magnetic field at $\theta = 0$ and get ρ_{\parallel} ; and at $\theta = 90^{\circ}$ and get ρ_{\perp} .

Use 4-point resistance measurements and a known geometry. Use a magnet to apply an external magnetic field and set $\theta = 0$. Set $I_x \neq 0$ and $I_y = 0$ and monitor V_x , to get R_x and then ρ_{\parallel} . Set $I_x = 0$ and $I_y \neq 0$ and monitor V_y , to get R_y and then ρ_{\perp} .

Orders of magnitude: mm device, mA, tenth of Ohms, mV

c) For Ni, $\frac{\Delta \rho}{\rho} \sim 2.5\%$ at room temperature.

The AMR effect was used in the first generation of sensors, like read heads in hard disk drives. Nowadays, most sensors are based on tunnel magnetoresistance with orbital filtering. Typical values of magnetoresistance are now greater than 100%. The temperature-dependence of AMR sensors can still be a plus for some applications.

d) From Eq. (3) we can deduce the following:

For J_{15} , we have $\theta = 0$ $V_{15} = \rho_{\parallel}J_{15}/d$ $V_{37} = 0$ V_{15} V_{37}

For J_{84} , we have θ =-45° $V_{84} = (\rho_{\parallel} + \rho_{\perp})J_{84}/(2d)$ $V_{26} = -(\rho_{\parallel} - \rho_{\perp})J_{84}/(2d)$



For
$$J_{73}$$
, we have θ =-90°
 $V_{73} = \rho_{\perp} J_{73}/d$
 $V_{15} = 0$

For J_{62} , we have θ =-135°

 $V_{62} = (\rho_{\parallel} + \rho_{\perp})J_{84}/(2d)$ $V_{84} = (\rho_{\parallel} - \rho_{\perp})J_{62}/(2d)$

e) The AMR effect is even in magnetization, *i.e.* it is invariant on magnetization reversal. It can be shown that $\frac{\Delta \rho}{\rho} \propto (M. J_e)^2$. The AMR responses from the two sublatices add up. Using the AMR effect is hence appropriate for characterizing/detecting a collinear antiferromagnet [P. Wadley *et al*, Science **351**, 587 (2016)].


Solutions to exercise 2

a1) The relation between J_s and μ_s is

$$J_s = \frac{1}{2e\rho_N} \frac{d\mu_s}{dy}$$
(a1)
Note: take $\sigma^{\uparrow} = \sigma^{\downarrow} = \sigma_N/2$

a2) The time-variation of the spin density $\tilde{\mu_s}$ results in spin diffusion, which is balanced by spin scattering. The transport equation becomes

$$\frac{d\tilde{\mu}_{s}}{dt} = D \frac{d^{2}\tilde{\mu}_{s}}{dy^{2}} - \frac{\tilde{\mu}_{s}}{\tau_{sf}^{*}},$$

$$i\omega\mu_{s} = D \frac{d^{2}\mu_{s}}{dy^{2}} - \frac{\mu_{s}}{\tau_{sf}^{*}},$$

$$\frac{d^{2}\mu_{s}}{dy^{2}} - \frac{1}{l_{sf}^{*}} \mu_{s} = 0 \qquad (a2)$$
with $l_{af}^{*} = \frac{l_{sf}^{*}}{dt} = \frac{l_{sf}^{*$

with $l_{sf}^{\#} = \frac{l_{sf}}{\sqrt{1+i\omega\tau_{sf}^{*}}}$ and $l_{sf}^{*} = \sqrt{D\tau_{sf}^{*}}$, where *D* is the diffusive constant and τ_{sf}^{*} is the

average spin-flip scattering rate.

a3) We have $l_{sf}^{\#} = \frac{l_{sf}^{*}}{\sqrt{1+i\omega\tau_{sf}^{*}}}$ with $\omega\tau_{sf} = 2\pi f\tau_{sf}^{*}$. The typical value of the resonance

frequency for a ferromagnet is $f \sim 10 \ GHz$ (with $\mu_0 H^{\sim} 0.1 \ T$), and the typical value of spinflip scattering rate is $\tau_{sf}^* \sim 1 \ ps$, so $\omega \tau_{sf}^* \sim 10^{11} \times 10^{-14} \ll 1 \Rightarrow l_{sf}^{\#} \sim l_{sf}^*$. Note that this condition is no longer true in the THz regime, for example for antiferromagnetic resonance. In the following, we consider that $l_{sf}^{\#} = l_{sf}^*$.

a4) At the boundaries, we have:

for
$$y = 0$$
, $J_s = \frac{1}{2e\rho_N} \frac{d\mu_s}{dy}(0) = J_s^0$,
for $y = d_N$, $J_s = \frac{1}{2e\rho_N} \frac{d\mu_s}{dy}(d_N) = 0$

a5) The solution of Eq. (a2) takes the form

$$\mu_{s}(y) = Ae^{y/l_{sf}^{*}} + Be^{-y/l_{sf}^{*}},$$

for $y = 0$, $\frac{1}{2e\rho_{N}} \frac{d\mu_{s}}{dy} = J_{s}^{0} \Rightarrow A - B = 2e\rho_{N}J_{s}^{0}l_{sf}^{*}$
for $y = d_{N}$, $\frac{1}{2e\rho_{N}} \frac{d\mu_{s}}{dy} = 0 \Rightarrow B = Ae^{2d_{N}/l_{sf}^{*}}$
 $\mu_{s}(y) = 2e\rho_{N}J_{s}^{0} \frac{l_{sf}^{*}}{1 - e^{2d_{N}/l_{sf}^{*}}} \left(e^{y/l_{sf}^{*}} + e^{-y/l_{sf}^{*}}e^{2d_{N}/l_{sf}^{*}}\right)$

$$\mu_{s}(y) = 2e\rho_{N}J_{s}^{0}\frac{e^{-d_{N}/l_{sf}^{*}}}{e^{-d_{N}/l_{sf}^{*}}}\frac{l_{sf}^{*}}{1-e^{2d_{N}/l_{sf}^{*}}}\left(e^{y/l_{sf}^{*}} + e^{-y/l_{sf}^{*}}e^{2d_{N}/l_{sf}^{*}}\right)$$
$$\mu_{s}(y) = -2e\rho_{N}J_{s}^{0}l_{sf}^{*}\frac{\cosh\left((y-d_{N})/l_{sf}^{*}\right)}{\sinh\left(d_{N}/l_{sf}^{*}\right)}$$

a6) Using the result of question a5) and Eq. (a1), we obtain

$$J_{s}(y) = -J_{s}^{0} \frac{\sinh((y-d_{N})/l_{sf}^{*})}{\sinh(d_{N}/l_{sf}^{*})}$$
(a6)

$$b1) J_{e} = \langle J_{e}(y) \rangle = \frac{1}{d_{N}} \int_{0}^{d_{N}} \theta_{SHE} J_{s}(y) dy = -\frac{1}{d_{N}} \int_{0}^{d_{N}} \theta_{SHE} J_{s}^{0} \frac{\sinh((y-d_{N})/l_{sf}^{*})}{\sinh(d_{N}/l_{sf}^{*})} dy$$

$$J_{e} = -\theta_{SHE} J_{s}^{0} \frac{1}{d_{N}} \frac{1}{\sinh(d_{N}/l_{sf}^{*})} \int_{0}^{d_{N}} \sinh((y-d_{N})/l_{sf}^{*}) dy$$

$$J_{e} = -\theta_{SHE} J_{s}^{0} \frac{l_{sf}^{*}}{d_{N}} \frac{1-\cosh(d_{N}/l_{sf}^{*})}{\sinh(d_{N}/l_{sf}^{*})} = -\theta_{SHE} J_{s}^{0} \frac{l_{sf}^{*}}{d_{N}} \frac{1-2\sinh^{2}(d_{N}/(2l_{sf}^{*}))+1}{2\sinh(d_{N}/(2l_{sf}^{*}))}$$

$$J_{e} = \theta_{SHE} \frac{l_{sf}^{*}}{d_{N}} \tanh\left(\frac{d_{N}}{2l_{sf}^{*}}\right) J_{s}^{0}$$

$$J_{e} = \theta_{SHE} \frac{l_{sf}^{*}}{d_{N}} \tanh\left(\frac{d_{N}}{2l_{sf}^{*}}\right) J_{s}^{0}$$

b2)
$$I = J_e l d_N = \theta_{SHE} l l_{sf}^* \tanh\left(\frac{d_N}{2l_{sf}^*}\right) J_s^0$$

 $\theta_{SHE} l l_{sf} J_s^0$

For $d_N \ll l_{sf}^*$, $I \sim \theta_{SHE} l \frac{d_N}{2} J_s^0$. Spins are still coherent and get converted efficiently in the N layer. The thicker the layer, the more spins are converted.

For $d_N \gg l_{sf}^*$, $I = \theta_{SHE} l l_{sf}^* J_s^0$. The signal levels out. The part of the N layer in contact with the F layer ($d_N < 2 - 3l_{sf}^*$) converts spins. Above $d_N \sim 2 - 3l_{sf}^*$ spin-charge conversion becomes inefficient because the spins are depolarized.

$$b2) V_{ISHE} = \frac{R_F R_N}{R_F + R_N} I = \frac{\frac{\rho_F w \rho_N w}{ld_F ld_N}}{\frac{\rho_F w}{ld_F} + \frac{\rho_N w}{ld_N}} J_e l d_N$$
$$V_{ISHE} = \frac{w d_N}{d_N \sigma_N + d_F \sigma_F} J_e$$
$$V_{ISHE} = \theta_{SHE} \frac{w l_{sf}^*}{d_N \sigma_N + d_F \sigma_F} \tanh\left(\frac{d_N}{2l_{sf}^*}\right) J_s^0$$

- b3) The Hall angle is $\theta_{SHE} \sim 6\%$ and the 'spin-charge conversion efficiency' is $\theta_{SHE} l_{sf}^* \sim 0.18 nm$ [J. C. Rojas-Sanchez *et al*, Phys. Rev. Lett. **112**, 106602 (2014)].
- b4) Increasing the number of scattering centers will increase the extrinsic contribution to θ_{SHE} , because for this extrinsic contribution $\theta_{SHE} \propto \frac{1}{l_{sf}^*}$, and increasing the number of scatterers will reduce l_{sf}^* . This solution is however not appropriate to increase the 'spin-charge conversion efficiency' because $\theta_{SHE} l_{sf}^*$ will remain unchanged.

Increasing the scattering efficiency by using heavier materials, with a large atomic number Z, is another solution to increase θ_{SHE} . Because spin-orbit interactions roughly vary as Z^4 , this solution will results in a large increase of 'spin-charge conversion efficiency'. Note however that other effects contribute to θ_{SHE} and the picture presented above is certainly more complicated. In particular, intrinsic contributions do matter.

c1)
$$\overline{\Gamma} = 2\omega \frac{\mu_0 M_S |\gamma| \sin^2(\theta_M) + \sqrt{(\mu_0 M_S \gamma \sin^2(\theta_M))^2 + 4\omega^2}}{(\mu_0 M_S \gamma \sin^2(\theta_M))^2 + 4\omega^2}$$

 γ is in unit of $Hz.T^{-1}$; $\mu_0 M_s$ is in T; and ω is in Hz, so we can conclude that $\overline{\Gamma}$ is a dimensionless parameter.

- c2) For $\theta_M = 0$, $\overline{\Gamma} = 1$. By definition, the magnetization trajectory in the (*x*, *y*) plane is circular. In this case, the magnetization rotates about the out-of-plane direction. If there is no inplane anisotropy, it is expected that the trajectory is circular. It would not be the case in the presence of an in-plane anisotropy.
- c3) The magnetization is mostly in-plane, whatever the angle of the applied field. This is because of the demagnetizing field.



 V_{ISHE} is an odd function of **H**. Angular-dependent symmetries are useful to disentangle the inverse spin Hall effect and several others that may occur concurrently [M. Harder *et al*, Phys. Rep. **661**, 1 (2016)]. When two effects share the same angular-dependent symmetries, frequency-, temperature-, stacking order- etc. dependences are used to unravel the contributions.